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Application No.	Applicant(s)	
10/706,755	KIM ET AL.	
Examiner	Art Unit	
Stephen W. Smoot	2813	

	10/706,755	KIM ET AL.	
Notice of Allowability	Examiner	Art Unit	
·	Stephen W. Smoot	2813	
The MAILING DATE of this communication apper All claims being allowable, PROSECUTION ON THE MERITS IS (herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIC of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this apported or other appropriate communication GHTS. This application is subject to	olication. If not included will be mailed in due course. T	HIS nitiative
1. This communication is responsive to applicant's amendment			
2. The allowed claim(s) is/are 1.3-5.7.8.22.23 and 26.			
3. ☑ Acknowledgment is made of a claim for foreign priority un a) ☑ All b) ☐ Some* c) ☐ None of the:			
1. Certified copies of the priority documents have			
Certified copies of the priority documents have			
 Copies of the certified copies of the priority doc International Bureau (PCT Rule 17.2(a)). * Certified copies not received: 	cuments have been received in this	national stage application from	the
•			
Applicant has THREE MONTHS FROM THE "MAILING DATE" on noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	of this communication to file a reply ENT of this application.	complying with the requirement	:s
4. A SUBSTITUTE OATH OR DECLARATION must be submit INFORMAL PATENT APPLICATION (PTO-152) which give	itted. Note the attached EXAMINER es reason(s) why the oath or declara	S AMENDMENT or NOTICE O tion is deficient.	F
5. CORRECTED DRAWINGS (as "replacement sheets") mus	t be submitted.		
(a) ☐ including changes required by the Notice of Draftspers		948) attached	•
1) ☐ hereto or 2) ☐ to Paper No./Mail Date			
(b) ☐ including changes required by the attached Examiner's Paper No./Mail Date			
Identifying indicia such as the application number (see 37 CFR 1, each sheet. Replacement sheet(s) should be labeled as such in the	.84(c)) should be written on the drawii he header according to 37 CFR-1.121(ngs in the front (not the back) of d).	
6. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT	sit of BIOLOGICAL MATERIAL (FOR THE DEPOSIT OF BIOLOGIC	nust be submitted. Note the AL MATERIAL.	
Attachment(s) 1. ☐ Notice of References Cited (PTO-892)	5. Notice of Informal F	atent Application (PTO-152)	
2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)	6. Interview Summary		
3. Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date	Paper No./Mail Da 98), 7. ☐ Examiner's Amendi		
4. Examiner's Comment Regarding Requirement for Deposit of Biological Material Output Date 1. Deposit Output Deposit Output Deposit Deposi	8. X Examiner's Statement	ent of Reasons for Allowance	
-	9.		
0.	1 1 0	Stephen W. Smoot Patent Examiner	

Stephen W. Smoot

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DETAILED ACTION

This Office action is in response to applicant's amendment received on 30 September 2005, which has been entered.

Allowable Subject Matter

- 1. Claims 1, 3-5, 7-8, 22-23, 26 are allowed.
- 2. The following is an examiner's statement of reasons for allowance:
 - Claims 1, 3-5, 7-8 are allowed because the prior art of record does not teach or suggest, in combination with the other claim limitations, an integrated circuit structure that includes an epitaxial silicon layer that extends from an active region of an integrated circuit substrate through an insulation layer beneath the active region to an underlying substrate, wherein the insulation layer includes a thermal oxide layer that extends from an inner side wall of a trench to beneath the active region; and
 - Claims 22-23, 26 are allowed because the prior art of record does not teach or suggest, in combination with the other claim limitations, an integrated circuit

structure that includes an isolation structure that electrically isolates an active region, the active region having a plurality of gates and having two insulation layers beneath the plurality of gates that extend between opposing portions of the isolation structure, wherein an epitaxial silicon layer extends from the active region through both insulation layers.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

3. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Stephen W. Smoot whose telephone number is 571-272-1698. The examiner can normally be reached on M-F (8:00 am to 4:30 pm).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl Whitehead, Jr. can be reached on 571-272-1702. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

SWS